Docket No.: P2001,0126

JUL 0 9 2004

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By My September 1

Date: July 6, 2004

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applic. No.

10/647,614

Confirmation No: 2856

Applicant

Ulrich Baier

Filed

August 25, 2003

Title

Method for Etching a Hard Mask Layer and a Metal Layer

Art Unit

2823

Examiner

Joannie A. Garcia

Docket No.

P2001,0126

Customer No. :

24131

<u>INFORMATION: DISCLOSURE STATEMENT</u> <u>UNDER 37 C.F.R. 1.97(i)</u>

Hon. Commissioner for Patents

Sir:

In accordance with 37 C.F.R. 1.98 copies of the following patents and/or publications are submitted herewith:

United States Patent No. 6,235,214 B1 (Deshmukh et al.), dated May 22, 2001;

English translation of Taiwanese Office Action, dated May 11, 2004.

As per the Notice in 1273 OG 55 (August 5, 2003) no copies of any abovementioned U.S. patents and U.S. patent application publications are submitted for any application filed after June 30, 2003. IfW

It is believed that the enclosed prior art is less pertinent than the prior art previously submitted and cited by the Examiner. Kindly place the references in the Patent Office file wrapper.

Respectfully submitted,

For Applicant

Date: July 6, 2004

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	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT BY APPLICANT (37 CFR 1.98(b))				Attorney Docket No P2001,0126	.: Ar	Applic. No. 10/647,614		
PE					Applicant Ulrich Baier				
M 0 8 3					Filing Date August 25, 2003	Group Art Unit 2823			
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	EXAMINER INITIALS		PATENT NO.	DATE	PATENTEE	CLASS	SUB CLASS	FILI DA	
		Α	6,235,214 B1	05/22/01	Deshmukh et al.				
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.